



Substitute for Form 1449 A & B/PTO

**INFORMATION DISCLOSURE
STATEMENT BY APPLICANT**

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Sheet 1 of 1

Substitute for Form 1449 A & B/PTO INFORMATION DISCLOSURE STATEMENT BY APPLICANT <i>(use as many sheets as necessary)</i>		<i>Complete if Known</i>	
Sheet	1	of	1
		Application Number	10/735,769
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		First Named Inventor	Koichi KAWAMURA
		Art Unit	1756
		Examiner Name	NOT YET ASSIGNED
		Attorney Docket Number	Q79007

U.S. PATENT DOCUMENTS

Examiner Initials*	Cite No. ¹	Document Number		Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document
		Number	Kind Code ² (if known)		
		US			
		US			
		US			

FOREIGN PATENT DOCUMENTS

NON PATENT LITERATURE DOCUMENTS

Examiner Initials*	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city, and/or country where published.	Translation ⁶
WD		YOSHINOBU TSUJII ET AL. : "Fabrication of patterned high-density polymer graft surfaces. II. Amplification of EB-patterned initiator monolayer by surface-initiated atom transfer radical polymerization", POLYMER, ELSEVIER SCIENCE PUBLISHERS B.V, GB, vol. 43, no. 13, June 2002, pages 3837-3841, XP004349557	
WD		RAHUL R. SHAH, ET AL., "Using atom transfer radical polymerization to amplify monolayers of initiators patterned by microcontact printing into polymer brushes for pattern transfer", MACROMOLECULES, vol. 33, no. 2, August 1, 2000, pages 597-605, XP002273494	
WD		KRZYSZTOF MATYJASZEWSKI, et al., "Atom transfer radical polymerization", CHEMICAL REVIEWS, AMERICAN CHEMICAL SOCIETY. EASTON, US, vol. 101, no. 9, December 9, 2001, pages 2921-2990, XP002212148	
		YOUNAN XIA, ET AL., "Soft Lithography", ANGEWANDTE CHEMIE. INTERNATIONAL EDITION, VERLAG CHEMIE. WEINHEIM, DE, vol. 37, 1998, pages 550-575, XP002149045	

Examiner Signature Abroth Charles Davis **Date Considered** 10/01/05

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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